



Round Titanium Sputtering Target Forged CNC Machining

Basic Information

- Place of Origin:
- Brand Name:Certification:
- N/M
- ISO9001:2015 certification

China

- Model Number:
- Minimum Order Quantity:
- Price:
- Packaging Details:
- Delivery Time:
- Supply Ability:



50000KG/month

- 10 piece Negotiable
- plywood case 5-35 working days
- iy me.



Product Specification

• Name:

. Key Words:

Application:

• Technique:

• Grade:

Density:Highlight:

- Titanium Target Plate Titanium Sputtering Target
- Coating, Electronics Industry
 - Forged,CNC Machining,Hot Rolled,Forged And CNC Machined
 - Gr1
- 4.51g/cm3
- Round Titanium Ti Target, CNC Machining Tantalum Target, Forged Aluminum Sputtering Target



Product Description

Customized Titanium Target Titanium Round Target

High-purity and high-density titanium sputtering targets include: Titanium sputtering target (purity: 99.9%-99.999%)





Usually we will provide a quality inspection report like this with the goods, which shows the chemical composition and physical properties

宝鸡丞德鑫钛金属材料有限公司

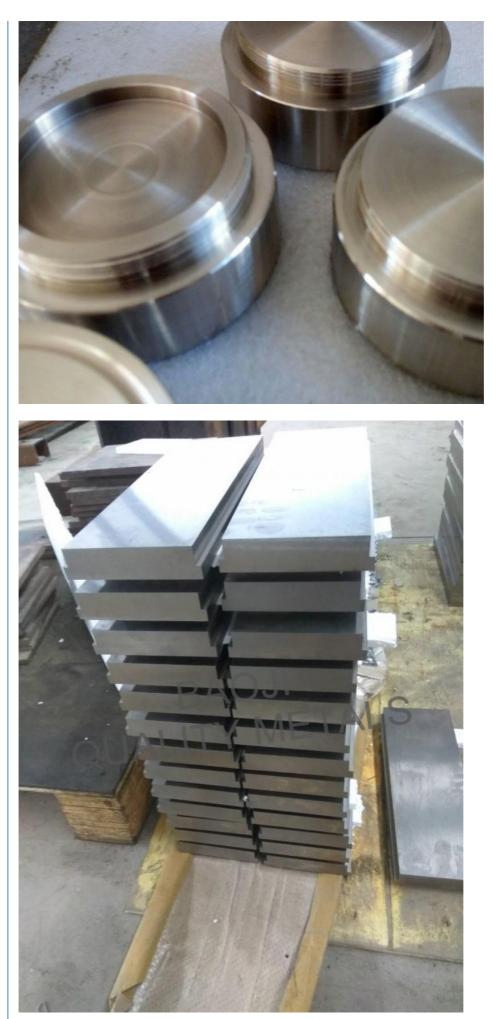
Baoji Quality Metals Co., Ltd

质量证明书 Quality Certificate

合同号。 Contract No.	产品名称 Description	斜 号 Designatio No.		批号 Lot No/能号 Heat No.			No	状态 Condition		规格 Size(mm)		数 量 Quantity	产品标准 Product Standard		
1	Titanium bar	GRI -		ÝTL20180126				м		16mm ×1000 mm		sample	ASTM B348		
室温力学性能 Tensile test	试验温度 (℃) Test Temperature	抗拉强度 Rm(MPa) Tensile Strength		屋服强度 Rp _{6.2} (MPa) Yield Strength			新后传长半 A(%) Elongation		断面收缩率 Z(%) Reduction of area			水压试验 Hydraulic pressure test		10000	压崩试验 Flattening text
	Result	526		400			26		50			合格	合格		合格
具 宅	弯曲试验 r [*] Bend Test	低信组织 Macrostructure /		高倍组织 Microstructure			外形尺寸 Fimensiona Inspection	ensional		表面质量 Visual Inspection		探伤者 Ultras Inspec	onic		7
Others	1				$T_{\rm c}$		合格		合 格			ok			1
				化	学 成	份(hemical	Compo	sition	(%)					
	n	AI	Su	1	1	1	1	F	e	C	N	н	0	Residu	ial element
Result	Remainder	1	1	1	1	1	1	0.	.11	0.06	0.02	0.001	0.07	$\leqslant 0, 10$	\$0.30
编制。 <u>兰宝宫</u> Prepared by					載潮。 Approx	编程 期间 质	組织 加加 量 检	時前 115 00 126 至	限公 [] [] [] []	THE CAL		限省日期h _20 Report Date	18年3月	15	

Terms of trade	EXW FOB CIF					
Payment terms	T/T , L/C					
packing	Plastic paper inside , plywood case outside					
Delivery time	In general,the delivery time is 5 days to 35 days. Please confirm the exact delivery time with us as different products and different quantity need different delivery time.					
MOQ	Small order quantity is acceptable					





Q: Why choose us? A1: We have 14 years experience for titanium products making. A2: sample order is acceptable. A3: lower price, good quality and short delivery time.

A4:The quotation can be make within 24 hours.

- A5: ISO9001:2015 certification
- A6: Give us drawing, make your drawings and ideas become a reality!

A7: Provide third-party quality inspection reports.

Processing various titanium targets for coating:

Metal targets: tungsten target, molybdenum target, tantalum target, niobium target, zirconium target, cobalt target, vanadium target, copper target, platinum target, hafnium target, niobium target, aluminum target, iron target, chromium target, titanium-niobium alloy target , titanium-zirconium alloy target, titanium-tungsten alloy target, titanium-gui alloy target, titanium-aluminum target, nickel-chromium alloy target, aluminum-chromium alloy target, high-purity titanium target, ultra-high-purity titanium target, high-purity tantalum target, high-purity aluminum target, (99.95%-99.999%),

Classification: Multi-arc ion coating target, titanium flat target, titanium rotary tube target, titanium target back plate, titanium target back tube

Uses: tool coating, decorative coating, electronics industry, flat panel display industry, large area Low-E glass coating, semiconductor, LCD, solar energy industry, optical lens, optoelectronic industry, ceramic binding target, spraying target, etc. Magnetron sputtering coating target:

Metal sputtering coating target, titanium sputtering target, alloy sputtering coating target, ceramic sputtering coating target, boride ceramic sputtering target, carbide ceramic sputtering target, fluoride ceramic sputtering target, oxide ceramic target, selenide ceramic sputtering target, silicide ceramic sputtering target, sulfide ceramic sputtering target, telluride ceramic sputtering target, other ceramic target Material, chromium-doped silicon oxide ceramic target (Cr-SiO), indium phosphide target (InP), lead arsenide target (PbAs), indium arsenide target (InAs).



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